

GEMOLOGICAL INSTITUTE

## **ELECTRONIC COPY**

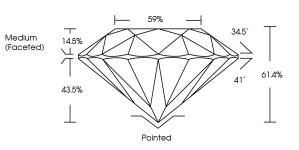
### LABORATORY GROWN DIAMOND REPORT

# PROPORTIONS

July 5, 2024				
IGI Report Number	LG640452394			
Description	LABORATORY GROWN DIAMOND			
Shape and Cutting Style	ROUND BRILLIANT			
Measurements	6.61 - 6.65 X 4.07 MM			
GRADING RESULTS				
Carat Weight	1.10 CARAT			
Color Grade	D			
Clarity Grade	VVS 2			
Cut Grade	IDEAL			
ADDITIONAL GRADING INFORMATION				

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	任闭 LG640452394

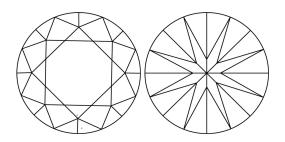
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



LG640452394

Report verification at igi.org

### **CLARITY CHARACTERISTICS**



#### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.



Sample Image Used

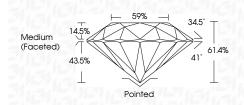
### COLOR

DEF	GHIJ	Faint	Very Light	Light
CLARITY ⊮	WS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	1-3
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included



# July 5, 2024

IGI Report Nur	nber LG640452394	4
Description	LABORATORY GROWN DIAMOND	)
Shape and Cu	tting Style ROUND BRILLIAN	ſ
Measurements	6.61 - 6.65 X 4.07 MM	1
GRADING RES	JLTS	
Carat Weight	1.10 CARA	r
Color Grade	C	)
Clarity Grade	VVS 2	2
Cut Grade	IDEAI	L



#### ADDITIONAL GRADING INFORMATION

Symmetry EXCELLENT Fluorescence NONE Inscription(s) (15) L6640452394 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.		
Fluorescence NONE Inscription(s) (5) LG640452394 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
Inscription(s) (CM LG64045239) Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	EXCELLENT
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Fluorescence	NONE
created by Chemical Vapor Deposition (CVD) growth process.	Inscription(s)	任到 LG640452394
- , po na	created by Chemical Vapo	





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